

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	)	
Christoph Moelle et al.	)	Group: 2872
Serial Ño.: 10/637,203	)	-
Filed: August 8, 2003	)	Examiner: M.Y. Sikder
Title: OBJECT WHICH HAS OPTICAL LAYERS	)	

## INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Applicant wishes to bring to the attention of the Examiner the document identified on the attached form PTO-1449. Applicants respectfully request that this document be made of record in the present application.

WO 96/27690 is mentioned in the previously cited United States published application US 2003/0021909. WO 96/27690 describes a PECVD ("plasma enhanced chemical vapor deposition") method and a device for the two-sided coating of substrates, preferably spectacle lenses, by means of microwave excitation. A distinct plasma is used for each surface to be coated. In order to keep the heat load of the substrate low, the use of a pulsed discharge is recommended. No mention is made of which uniformities can be obtained in the coating and how they can be influenced.

Applicants' German representative has advised that this means that the process is a plasma impulse chemical vapor deposition process.

If any fees are necessary in connection with this document, or insufficient fees are sent herewith, please charge Deposit Account No. 02-0385, Baker & Daniels.

Respectfully submitted,

John K. Hoffman Registration No. 26,280 Attorney for Applicant

JFH/pmp

**BAKER & DANIELS** 

Suite 800

111 East Wayne Street Fort Wayne, IN 46802

Telephone: 260-424-8000 Facsimile: 260-460-1700

Enc. Form PTO-1449

Cited Reference

Date: November 10, 2004

IPE					WEI0024-02 10/637,203							
	INFO	RMATION DISCLOSOR	<b>)</b>		Applicant(s) Christoph Moelle	et al.						
1			15 2004		Filing Date		Group Art Unit					
			· • • • • • • • • • • • • • • • • • • •	August 8, 2003 2872								
*EXAMINER DES DOCUMENTS DUES DUES FILING DATE												
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME CLASS SUBCLASS			SUBCLASS	FILING DATE  IF APPROPRIATE				
					-							
								-				
U.S. PATENT APPLICATION PUBLICATIONS												
*EXAMINER INITIAL			DATE		NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE				
			FORI	EIGN PATE	ENT DOCUMENTS							
,	REF	DOCUMENT NUMBER	DATE		COUNTRY	CLASS	SUBCLASS	Tran: YES	slation NO			
		WO 96/27690	09/1996 PCT ( <sup>3</sup>		(*)			1				
					***************************************							
				<u> </u>								
	<del></del>	····	OTHER	DOCUMEN	NTS (Including A	uthor, Title, Date, I	Pertinent Pages, E	(c.)				
		(*) = English language abstract only										
						<del></del>	·					
EXAMINER				DATE CONSIDERED								
		al if citation considered, whether clude copy of this form with next			nce with MPEP Section 6	09; Draw line thro	ugh citation if not	in conform	ance and			